

Notice of References Cited		Application/Control No. 10/549,444	Applicant(s)/Patent Under Reexamination SION ET AL.	
		Examiner DAVID TUROCY	Art Unit 1792	Page 1 of 1

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*	Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A US-6,210,745	04-2001	Gaughan et al.	427/8
*	B US-6,001,419	12-1999	Leluan et al.	427/249.2
C	US-			
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I	US-			
J	US-			
K	US-			
L	US-			
M	US-			

FOREIGN PATENT DOCUMENTS

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NON-PATENT DOCUMENTS

*	Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)	
*	U	Glasier et al. Formation of pyrolytic carbon during the pyrolysis of ethane at high conversions. Carbon 39 (2001) 15-23.
*	V	Birakayala et al. A reduced reaction model for carbon CVD/CVI processes. Carbon 40 (2002) 675-683.
	W	Chemical Vapor Infiltration, http://en.wikipedia.org/wiki/Chemical_vapor_infiltration
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a))
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.